

Applicant:

Piao et al.

Title:

CONFIGURABLE RETICLE FOR

LITHOGRAPHY AND A METHOD

OF MAKING INTEGRATED CIRCUITS USING SUCH A

RETICLE

Appl. No.:

09/775,059

Filing

02/01/2001

Date:

Examiner:

Unknown

Art Unit:

2811

ATTENTION: DRAWING REVIEW BRANCH U.S. Commissioner of Patents and Trademarks

Washington, D.C. 20231

CERTIFICATE OF MAILING I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as First Class Mail in an envelope addressed to: Commissioner for Patents, Washington, D.C. 20231, on the date below. Chris Escavaille (Signature) March 29, 2002 (Date of Deposit)



REQUEST TO APPROVE DRAWING CHANGES

The Applicant hereby proposes to revise the drawings as hand-corrected on the attached drawing sheet (Fig. 2). The Applicant will submit new formal drawings upon allowance of the application. Approval of the proposed drawing changes is hereby respectfully requested.

Respectfully submitted,

Attorney for Applicant Registration No. 35,421

Date

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